





James J. Pohl John T. Haran Mark W. Rygiel Michael R. Malek Carla Ji-Eun Kim Doyle A. Steven' Ix Doyle A. Steven' Ix See J. All Carlo Doyle A. Steven' Ix See J. All Carlo J. Carlo J.

eishe hyllon-Nodic onnie Nannenga-Comi hyssa K. Sandrowitz obathan M. Svang shan P. Weerskoon benghus Luo ehador M. Bezor nuc B. Vanne ustn T. Sher yron L. Prickard ellie K. DiNapoli hiristopher B. Fregnc' office R. Fougere William P. Ladd'

Yasser Mourtads
Cytthia L. DeRenzo
Omar F. Amin
R. Wilson Powers III
Bin C. Weng
Joseph E. Mutschelkna
Kavon Nasabadah
Aaron S. Ward
Of Counsel
Edward J. Keisler
Kenneth C. Bass III
Christopher P. Wrist

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August 10, 2009

WRITER'S DIRECT NUMBER:
(202) 772-8856
INTERNET ADDRESS:
KMCCABE@SKGF.COM
Mail Stop Issue Fee

Commissioner for Patents PO Box 1450 Alexandria, VA 22313-1450

dria, VA 22313-1450

Re: Allowed U.S. Utility Patent Application

Allowed U.S. Utility Patent Application
Appl. No. 10/587,887; Filei: July 27, 2006
For: System for High Dynamic Range Analysis in Flow Cytometry
Inventor: Theodore W. JOCHUM
Our Ref: 2512.1550001 (041 IS0070)

Sir:

In response to the Notice of Allowance and Fee(s) Due dated May 15, 2009, the following documents are transmitted for appropriate action by the U.S. Patent and Trademark Office:

- Issue Fee Transmittal (Form PTOL-85); and
- Online Credit Card Payment Authorization for \$1,810.00 to cover:

\$1,510.00 - Issue Fee; and \$ 300.00 - Publication Fee.

The above-listed documents are filed electronically through EFS-Web.

Fee payment is provided through online credit card payment. The U.S. Patent and Trademark Office is hereby authorized to charge any fee deficiency, or credit any overpayment, to our Deposit Account No. 19-0036.

Respectfully submitted,

STERNE, KESSLER, GOLDSTEIN & FOX P.L.L.C.

Kevin W. McCabe Attorney for Applicant Registration No. 41,182

KWM/IPW:smn Enclosures

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